#5/amd+A 3/3/00 C. McKenney

PATENT APPLICATION Docket No. 11675.23

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:		)
	Cathey, et al.	) ) 
Serial No.:	09/031,617 FEB 2 8 2000	) Art Unit ) 2822
Filed:	February 27, 1998	) )
For:	MOCVD PROCESS USING OZONE AS A	
	REACTANT TO DEPOSIT A METAL OXIDE BARRIER LAYER	) 5
Examiner:	James Park	) )
	AMENDMENT A UNDER 37 C.F.R. § 1.111	

The Honorable Commissioner of Patents and Trademarks
Washington, D. C. 20231

Sir:

In response to the Office Action mailed on November 26, 1999 (the "Office Action"), the Applicants submit this Amendment A and response.

## **IN THE DRAWINGS**

Submitted herewith, by a separate paper, is a corrected Figure 1, sheet 1 of 2, as indicated in red. Support for the correction in found in the specification at Page 4, line 22. The Applicants request that any requirements for formal drawings be held in abeyance until such times as allowable subject matter has been indicated.

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